Translation of JP 1-156725 6/20/9

#### Specification

- 1. Title of the invention Display device
- 2. What is claimed is:

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- (1) A display device comprising:
- a two dimensional active elements array, wirings which provide said active elements with signals, and pixel electrodes connected to said active elements array formed on a first insulating substrate;
- a counter electrode formed on a second insulating substrate; and an electro-optical material disposed in a gap between said first and second substrates facing each other;

wherein said active elements and said wirings are covered with an insulating film at least partly, and the pixel electrodes are provided on said insulating film.

- (2) The display device of claim 1 wherein said pixel electrodes are arranged such that at least a part of a gap between said pixel electrodes is located over said wirings.
- (3) The display device of claim 1 wherein a thickness of said insulating film which covers said active elements and wirings is small on said active elements and wirings, and large on other portions.
- (4) The display device of claim 1 wherein said pixel electrodes are formed with a metal thin film.
  - 3. Detailed description of the invention

# [FIELD OF THE INVENTION]

The present invention relates to a structure of a display device.
[DESCRIPTION OF THE PRIOR ART]

An example of conventional display device using electro-optical material is shown in Nikkei Electronics, September 10, 1984, No. 351, P. 211-240. Fig. 2 shows an example of plan view of the display device.

In Fig. 2, a thin film transistor, that is TFT 14 is arranged on intersection of data line 12 and scanning line 13, and pixel electrode 11 is connected each TFT. In Fig. 3 which shows an example of cross section, reference numerals 20 and 30 show insulating substrates, reference numerals 21, 22, and 23 show a source portion, a drain portion, and a channel portion, respectively. Reference numeral 24 shows a gate insulating film, 25 shows a gate electrode, 26 shows an interlayer insulating film, 27 shows a data line, 28 shows a pixel electrode, and 31 shows a counter electrode. An electro-optical material 29 such as liquid crystal, which is disposed between two substrates, is driven by an electric field between the pixel electrode 28 and the counter electrode 31.

# [PROBLEMS THE PRESENT INVENTION INTENDS TO SOLVE]

However, the above mentioned prior art has following problems. That is, it is necessary to reduce the area of pixel if the prior art intends to realize high definition of display portion of the display device. However, it is usually difficult to reduce the area of active elements and wiring portion, and the area proportion that the pixel electrodes occupy decreases. It is only pixel electrode region that image could be displayed thereon. Therefore, if the ratio of the pixel electrodes decreases, the contrast ratio decreases and an image quality is extremely damaged. In order to increase the contrast ratio, other than pixel electrode portion may be intercepted from light, however, the display portion is dark.

The present invention intends to solve the problem. An object of the present invention is to realize a display device having a high contrast ratio and a brightness of display image even if high definition of device is realized.

# [MEANS TO SOLVE THE PROBLEMS]

The display device of the present invention is characterized by an insulating film which covers at least a part of active elements and wirings, and arranges pixel electrodes thereon.

#### [EFFECT]

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In accordance with the above mentioned structure of the present

invention, area proportion occupied by pixel electrodes is rarely changed by realization of high definition of pixel. Therefore, it does not happened that the contrast ratio decreases and display portion becomes dark.

#### [EXAMPLE 1]

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Fig. 1 shows a plan view and Fig. 4 shows a cross section of Example 1 in accordance with a display device of the present invention. present example uses TFTs as active elements and liquid crystal as an The display device comprises data lines 2, electro-optical material. scanning lines 3, and TFTs 4 and pixel electrodes 1 which are provided at the intersection between these lines. A source electrode of a TFT is connected with a data line 2, a gate electrode is connected with a scanning line 3, and a drain electrode is connected with a pixel electrode 1. The TFT is used as a switching element to provide the pixel electrode with a signal of the data line. In Fig. 4, reference numeral 40 shows an insulating substrate, 41, 42, 43, and 45 show source, channel, drain, gate portions of the TFT, respectively, 44 shows a gate insulating film, 46 shows an interlayer insulating film, and 47 shows a data line. accordance with the present example, another layer of insulating film 52 is deposited on the device and pixel electrode 48 is formed thereon, therefore, it is possible to cover the upper portion of TFT and data line Reference numeral 50 shows another with the pixel electrode. insulating substrate, 51 shows a counter electrode comprising a transparent conductive film, 49 shows liquid crystal. The Liquid crystal 49 is driven between the counter electrode 51 and the pixel electrode The pixel electrode 48 is formed by using a transparent conductive film and a polarizing plates are arranged over and under the two insulating substrates to form a transmission display device. As the same with the first time, when the pixel electrode is arranged on the data line and scanning line, these wirings work as a light shielding layer and light which transmits through other part can be used effectively to realize display device having high contrast and bright display portion. On the other hand, a reflection type display device is made when a metal such as aluminum, gold, or platinum is used as the pixel electrode 48 by using polyimide or glass as an insulating film 52 and providing a planarized upper surface by coating in a liquid phase. In case that reflection type

is used, it is no need to increase space between TFTs, therefore, it is possible to realize a display having extremely high definition. substrate also can be used for a reflective display device, however, if image is displayed on large area, it is not appropriate because of large parasitic capacity of wirings. It is necessary to use an insulating substrate in order to obtain wide vision having high definition picture. Moreover, brightness of image does not change even if each pixel has a holding capacitor in order to improve the projection type display device. For example, it is possible to add capacitor of several to several ten times as much as liquid crystal by using MOS capacity or the like. this way, an image having a high contrast over a very wide temperature range and a high uniformity over the display can be obtained with a high reproducibility. An applied example of the display device is a projection type display device or the like. The display device of the present invention is a thin type and can display an image of high definition and high quality. Therefore, if the display device is used as a light valve of a transmission type or reflection type, it is possible to obtain projection type display device which is thin type and can display image of high definition on a wide vision.

### [Example 2]

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Fig. 5 shows a cross section of a display device using another TFT having a different structure from one of Example 1. In accordance with the present example, a gate electrode 45 is under a channel portion, therefore, a gate insulating film 44 can be replaced with an interlayer insulating film. Compared with Fig. 4, one insulating layer is omitted. It is possible to obtain same image by forming a pixel electrode 48 after forming an insulating film 52 in a similar way of Example 1.

# [Example 3]

Fig. 6 shows a cross section of a display device in accordance with the Example 3 of the present invention. In the example, a two terminal non-linear resistance element is used as an active element instead of the TFT. In case that two terminal element is used, only scanning line 65 is used as wirings on the first insulating substrate 60 and counter electrode 71 formed on the second insulating substrate 70 is in the state of stripe, therefore, it can be used instead of data line. Compared with

TFT, two terminal element has a simple structure, for example, when a MIM diode is used as the two terminal element, an insulating film 64 is disposed between a metal electrode 62 and scanning line 65 comprising metal to utilize non-linear resistance. As another example of a two terminal element, a diode ring, nin diode MSI diode or the like. In any way, if an insulating film 72 is formed on the element, and a pixel electrode is formed thereon in order to arrange space between the pixel electrodes on a scanning line, it is possible to obtain brightness of the image having a high contrast even in the case of a high definition.

#### [THE EFFECT OF THE INVENTION]

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As mentioned above, in accordance with the display device of the present invention, the area occupied by pixel electrodes can be maximized, therefore, even if the pixels are high density, picture portion is not dark. Moreover, wirings work as a light shielding layer, therefore, it is possible to obtain high contrast ratio. Further, only pixel electrodes and counter electrodes are arranged on a surface contacted with electro-optical material such as liquid crystal and other wirings are arranged under an insulating film. Therefore, necessary signal voltage is applied on the electro-optical material. As a result, transmission and reflectance of all pixels are same, and confidence of electro-optical material is improved.

On the other hand, in case that the display device is used as a reflective type, fine image having a high contrast over a very wide temperature range and a high uniformity over the display device can be obtained by adding a holding capacitor. Also, since the offset voltage which occurs due to the parasitic capacitance of the active elements during switching almost disappears, the flicker does not occur and the reliability of the electro-optical material is further increased.

# [BRIEF DESCRIPTION OF THE DRAWINGS]

Fig. 1 shows a plan view of a display device.

Fig. 2 shows a plan view of conventional display device.

Fig. 3 shows cross section of conventional display device.

Fig. 4, 5, and 6 show cross section of display device.

1, 11, 28, 48, 68 . . . pixel electrode

52, 72 insulating film
2, 12 data line
3. 13 scanning line

(54) DISPLAY DEVICE

(11) 1-156725 (A) (43) 20.6.1989 (19) JP

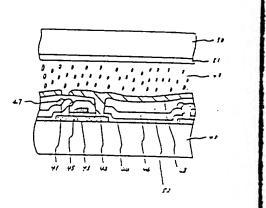
(21) Appl. No. 62-316708 (22) 15.12.1987

(71) SEIKO EPSON CORP (72) YOJIRO MATSUEDA

(5i' Int. Cl4. G02F1/133.G09G3/36

PURPOSE: To improve the quality of an image by arranging picture element electrodes on an insulating film which covers at least part of an active element and wiring.

CONSTITUTION: There is the insulating film on the element and there are picture element electrodes 4 on it, so thin film transistor TETs 41, 42, 43, and 45 and a data line 47 are covered with the electrode 48. Liquid crystal 49 is driven with an electric field between a counter electrode 51 and the electrode 48. The electrode 48 is formed of a transparent conductive film and polarizing plates are arranged on and under insulating substrates 40 and 50 to form the transmission type display device; when the gap between electrodes 43 is positioned right on the line 47 and a scanning line, wiring operates as a light shield layer and light transmitted through other parts is used effectively to obtain a bright picture with a high contrast ratio, thereby obtaining the excellent image quality.



349/138

9日本国特許庁(JP)

10 特許出頭公開

### 母公開特許公報(A)

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G 02 F 1/133 G 09 G 3/36 7370-2H 8621-5C

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母発明者 松枝

;± — aπ

長野県諏訪市大和3丁目3番5号 セイコーエアソン株式

会社内

②出 顋 人 セイコーエブソン株式

東京都新宿区西新宿2丁目4番1号

全社

远代 理 人 弁理士 最上 務 外1名

明 組 :

#### 1. 発明の名称 表示装置

2. 特許請求の延囲

(1)第1の地球基板上に2次元の電勤業子アレイと、前記能動業子に信号を供給する配談と、前記各能動業子に接続された憲業電腦とを確え、第1及び第2の地域基板上には対向電腦を確え、第1及び第2の地域基板を対向させて成る同域に電気光学材料を封入して成る表示装置において、前記能動業子及び配談上の少なくとも一部を覆う地域でを請え、前記地域製上に画業電腦を配置したことを特徴とする表示装置。

(2) 新記画素電優は、各直素電暖間の間線の少なくとも一部が新記配後上に位置するように配置されたことを特徴とする特許消水の範囲第1項記載の表示装置。

(3) 将起胎動素子及び配は上き渡う地址器の厚

みは、前記船動業子及び配線上では薄く、その他 の部分では厚く形成されていることを特徴とする 特許額束の範囲第1項記載の表示装置。

(4) 前記画業電気が金銭運獲で形成されている ことを特徴とする特許請求の範囲第1項記載の表示装置。

#### 3. 発明の詳細な説明

〔産業上の利用分野〕

本発明は、表示装置の構造に関する。

〔従来の技術〕

従来の電気光学材料を用いた表示装置の例としては、「日経エレクトロニクス 1984年9月10日号 No. 351 P. 211-2401に示されるようなものがある。第2回は表示装置の平面回の例であり、データは12と走立は13の交点に薄積トランジスタナなわら下ド下14が配置され、各下ド下には通常電腦11が提送されている。第3回は新面回の例であり、20及び30は絶縁面板、21、22、23はそれぞれ下ド

#### 詩聞平1-156725 (3)

高品質の画像を表示できるためこれを透過型または反射型のライトバルブとして用いると小型の姿質で高品質がつ大画面の画像を表示できる技材型表示装置が実現できる。

#### 〔実権例2〕

第5回は、第1の実施例と異なる内造の下下下を用いた表示装置の断面図の例である。本実施別においてはゲート電報45がチャネル部の下別にあったが、ゲート連接限44が層面連接要の代わりとなる。第4回と比較すると連接限が一種少なくなっている。この概な構造の下下でも第1の大変を同じに連接限5~2を形成した使蓋素電路できる。

#### (実施所3)

第6回は本発明の第3の実施例を示す表示装置 の画面図の例である。この例では最勤素子として TFTの代わりに2端子型非視形紙抗素子を用い る。2端子素子を用いる場合、第1の絶縁蓋至6 0上には配復は走変線65のみで、第2の絶縁蓋

他の配該は地種額の下にあるため、電気光学材料には必要な信号電圧のみが印加される。したがって画素のすみずみまで透過事または反射率が一般となり高品質の画像が得られ、電気光学材料の信頼性も向上する。

一方、反射型の表示装置として用いる場合には、保持容量を付加することにより高層組かつ高コントラスト比で面内 均一性の極めて良い面像を、広い温度延囲で再現性良く得ることができる。また、飛動素子の寄生容量によってスイッチング時に生じるオフセット 電圧もほとんどなくなるため、フリッカーがなくなり電気光学科科の信頼性も一段と向上する。

#### 4.図面の簡単な説明

第1回は表示装置の平面図。 第2回は従来の表示装置の平面図。 第3回は従来の表示装置の手面図。

第4、5、6回は表示装置の新面図。

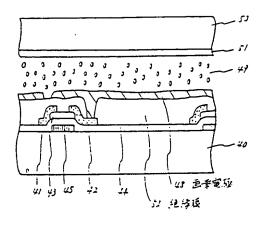
#### 〔発明の効果〕

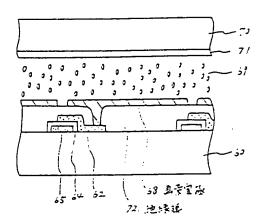
以上述べたように本を明の表示装置は、国業は のの占有面積を最大にすることができるため、同 業を高速度化しても画面が新くならない。しかも、 配後が返光値として働くためコントラスト比も大 きくとれる。さらに、孤晶等の電気光学材料に接 する表面には画業電腦と対向電腦のみが配置され、

以上

出類人 セイコーエアソン株式会社 代理人 弁理士 最 上 啓(他1名)

### 持備平1-156725 (5)





第5四

第6回